

## John Amara



Research Chemist

Biotechnology

<http://www.directoryinventor.com/profile/view/NoSUTIQU>

## Experience

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### Research Chemist III

EMD Millipore

10,001+ employees; Public Company; Pharmaceuticals  
2009 - Present

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### Senior Scientist

Rohm and Haas Electronic Materials

10,001+ employees; Public Company; Semiconductors  
June 2006 - November 2009

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## Education

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### Massachusetts Institute of Technology

Organic Chemistry

2001 - 2006

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### Boston College

Chemistry

1997 - 2001

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### Malden Catholic

1993 - 1997

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## Patents (4)

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### Coating compositions suitable for use with an overcoated photoresist

John P Amara, James F Cameron, Jin Wuk Sung, Gregory P Prokopowicz

January 6, 2011: 20110003250-A1

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### Coating compositions suitable for use with an overcoated photoresist

James F Cameron, Jin Wuk Sung, John P Amara, Greogory P Prokopowicz, David A Valeri, Libor Vyklicky, Wu Song S Huang, Wenjie Li, Pushkara R Varanasi, Irene Y Popova

November 25, 2010: 20100297557-A1

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## **Coating compositions suitable for use with an overcoated photoresist**

James F Cameron, Jin Wuk Sung, John P Amara, Gregory P Prokopowicz, David A Valeri  
November 25, 2010: 20100297556-A1

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## **Coating compositions for use with an overcoated photoresist**

John P Amara, Nicola Pugliano, Jin Wuk Sung, Michael K Gallagher, Michael S Castorano  
June 11, 2009: 20090148789-A1

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[View all \(4\)](#)